



## INFORMATION DISCLOSURE STATEMENT

Applicants : Chih-Hsing Cheng et al.  
App. No : 10/771,176  
Filed : February 3, 2004  
For : SOL-GEL-DERIVED HALOGEN-DOPED GLASS  
Examiner : Lisa L. Herring  
Art Unit : 1731

## CERTIFICATE OF MAILING

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

June 8, 2005

(Date)

Bruce S. Itchkawitz, Reg. No. 47,677

**Mail Stop Amendment**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing thirty-two (32) references to be considered by the Examiner. Also enclosed are three (3) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the receipt of a first Office Action on the merits, and presumably no fee is required. If a first Office Action on the merits was mailed before the mailing date of this Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON &amp; BEAR, LLP

Dated: 6/8/05

By:

Bruce S. Itchkawitz  
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# INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Application No.	10/771,176
Filing Date	February 3, 2004
First Named Inventor	Chih-Hsing Cheng
Art Unit	1731
Examiner	Lisa L. Herring
Attorney Docket No.	SITECH.017CP1CP

(Multiple sheets used when necessary)

SHEET 1 OF 2

## U.S. PATENT DOCUMENTS

Examiner Initials	Page No.	Document Number	Publication Date	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	1	2,092,163	09/07/1937	Johnson et al.	
	2	2,441,422	05/11/1948	Kriebel et al.	
	3	3,615,312	10/26/1971	Landry et al.	
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	5	4,317,668	03/02/1982	Susa et al.	
	6	4,681,615	07/21/1987	Toki et al.	
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	14	5,343,633	09/06/1994	Wang et al.	
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	19	6,492,072 B2	12/10/2002	Moore et al.	
	20	6,541,168 B2	04/01/2003	Brown et al.	
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	22	6,606,883 B2	08/19/2003	Hrdina et al.	
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	24	6,884,822 B2	04/26/2005	Wang et al. (Knobbe Martens Atty. Docket No. SITECH.004CP1)	
	25	US 2003/0069122 A1	04/10/2003	Wang et al. (Knobbe Martens Atty. Docket No. SITECH.004A)	
	26	US 2003/0078153 A1	04/24/2003	Wang et al. (Knobbe Martens Atty. Docket No. SITECH.004CP2)	

Examiner Signature

Date Considered

\*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  <i>(Multiple sheets used when necessary)</i>	Application No.	10/771,176
	Filing Date	February 3, 2004
	First Named Inventor	Chih-Hsing Cheng
	Art Unit	1731
	Examiner	Lisa L. Herring
SHEET 2 OF 2	Attorney Docket No.	SITECH.017CP1CP

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	27	US 2003/0147605 A1	08/07/2003	Wang et al. (Knobbe Martens Att. Docket No. SITECH.017A)	
	28	US 2003/0147606 A1	08/07/2003	Wang et al. (Knobbe Martens Att. Docket No. SITECH.017CP1)	
	29	U.S. Pat. App. No. 11/115,071	04/26/2005	Wang et al. (Knobbe Martens Att. Docket No. SITECH.004CP1C1)	

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document	Publication Date	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>
	30	EP 0 652 184 A1 (Patent)	05/19/1995	Alcatel Cable Interface		
	31	EP 0 652 184 A1 (Abstract)	05/19/1995	Alcatel Cable Interface		

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author, title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>
	32	SHIBATA, Shuichi, et al., "Fabrication of F-Doped Silica Glasses by the Sol-Gel Method," <u>Journal of Applied Physics</u> , Vol. 23, No. 11, November 1986, pp. L902-L904.	

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